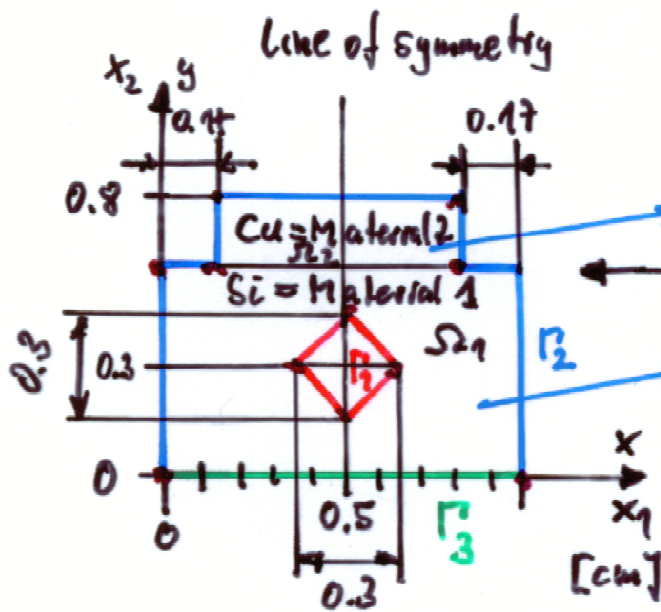


Example CHIP:



- $f \equiv 0$ (no heat sources)
- $\alpha \equiv 0$ (heat isolation in z -dir.)
- $\lambda(x) = \lambda_2 = \lambda_{Cu} = 3.95 \left[\frac{W}{cm \cdot K} \right]$ Cu interface Γ_I (copper)
- $\lambda(x) = \lambda_1 = \lambda_{Si} = 0.01 \left[\frac{W}{cm \cdot K} \right]$ Si (Silicon)
- $\Gamma_1 : q_1 = \text{const} = 500 [K]$
- $\Gamma_2 : q_2 = 0$ (isolation)
- $\Gamma_3 : \frac{\partial u}{\partial n} := \lambda_{Si} \frac{\partial u}{\partial n} = -\lambda_{Si} \frac{\partial u}{\partial y} = \alpha(u_0 - u)$
with $\alpha = 0.2 \left[\frac{W}{cm^2 \cdot K} \right]$
 $u_0 = 300 [K]$

Remarks:

1. $\exists! u \in V_g : (2)$ are ensured for the given data (\Rightarrow Ex. 2.2)!
2. The solution u has a sharp bend ("Knick") at the interface, i.e. $u \notin H^2(\Omega)$, but only $u \in H^{1+s_i}(\Omega)$ with some $s < 1/2$!
3. Loss of regularity of the solution u due to
 - corners at Γ , in particular, with inner angles $> \pi$,
 - changes of the BC on Γ ,
 - corners in the interfaces Γ_I (that is not the case here!),
 - interface Γ_I meets the boundary Γ ; $\Rightarrow u \in H^{1+s_i}(\Omega_i)$ with some $s_i : 1/2 < s_i < 1$.